

Formation and microstructural characterization of copper oxide thin films



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INTRODUCTION & AIM

Renewable energy

Increase of energy demand → Utilization of new energy
ex.) **Solar**, wind, hydro, geothermal, biomass
→ Research on **solar cells** is especially active.



Solar cells

- Perovskite (Organic-inorganic hybrid crystal)
- Flexible structure, high conversion efficiencies
- Cons. Low stability • High cost

CuO device

- Highly stable crystal and lower toxicity
- Complex deposition methods • High temperature annealing
- Improvement of electrical properties by doping elements

Aim

CuO thin films were fabricated using a simple spin-coating method, which will help in their application to solar cells.

METHOD

Solutions

Compact TiO₂ precursor solution : Ti diisopropoxide bis (acetyl acetonate) and 1-butanol were mixed.

Mesoporous TiO₂ precursor solution : Mainly, it was prepared by mixing titanium oxide powder with pure water.

CuO precursor solution : CuCl₂ was dissolved in pure water and then mixed with a surfactant.

Mg-added CuO precursor solution : CuCl₂ and MgCl₂ were mixed with CuO solution at their desirable concentrations.

Fabrications

1. Compact TiO₂ solution was spin-coated and dried twice on a cleaned FTO substrate and annealed.
2. Mesoporous TiO₂ solution was spin-coated and annealed.
3. CuO solution was spin-coated and annealed under various conditions such as spin-coating times, annealing temperature and time.
4. Gold (Au) was deposited for the device electrode.

RESULTS & DISCUSSION

Microstructures

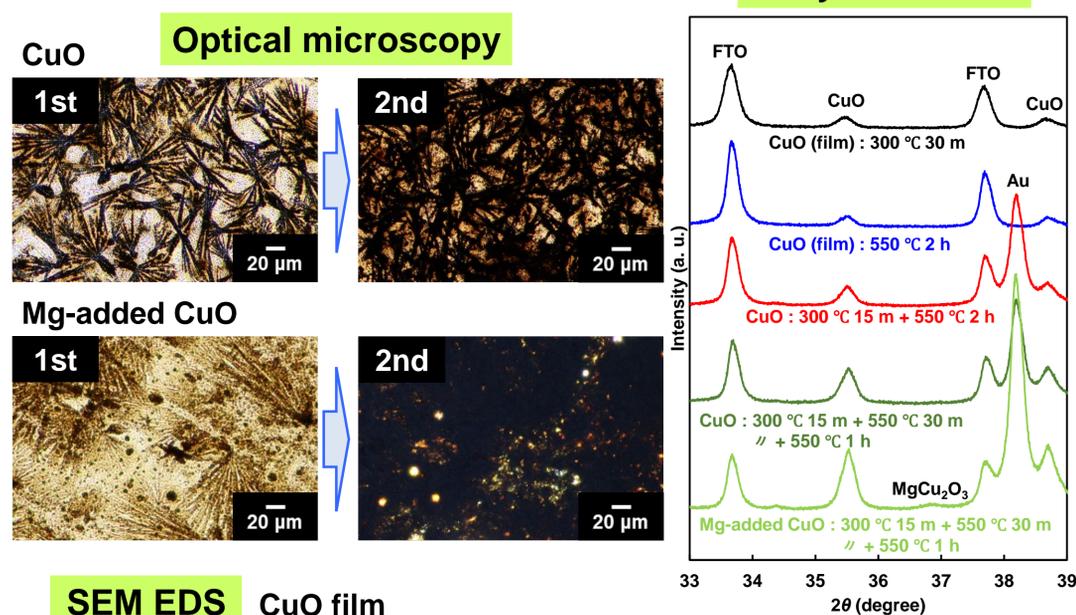
- Observation of strong XRD peaks derived from CuO
- MgCu₂O₃-derived peak around 36.8°

Surface morphology observation

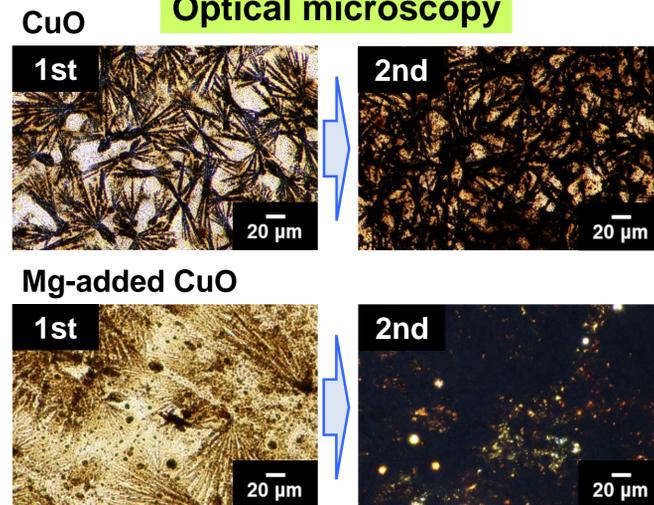
- Decrease in void area due to two deposition operations
- CuO: Flower-shaped crystals with spreading pillar structure
- Confirmation that photoelectric conversion is possible upon light irradiation (Current density-voltage measurements)

⇒ **Spin-coating and annealing twice each are necessary for uniform thin film formation.**

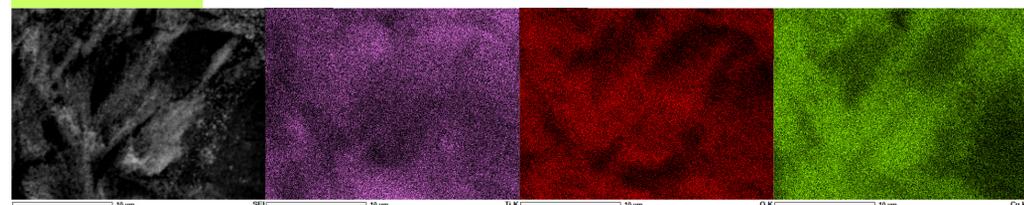
X-ray diffraction



Optical microscopy



SEM EDS CuO film



CONCLUSION

- Copper oxide thin films were successfully deposited using a spin-coating method.
 - CuO-derived peaks were observed in the fabricated thin films, indicating that spin-coating and annealing twice is effective for achieving uniform film formation.
- The spin-coated CuO thin films demonstrated potential for application in solar cells and provided a foundation for future optimization of thin film fabrication processes.

Compact TiO₂
Spin-coating
550 °C, 30 min

Mesoporous TiO₂
Spin-coating
550 °C, 30 min

CuO or
Mg-added CuO
Spin-coating
1. 550 °C, 30 min
2. 550 °C, 60 min

Air blowing

Au
Vacuum deposition

